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APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.
09/992,192	11/13/2001	Michael R. Krames	M-11040-3P US	7009

32566 7590 06/16/2003

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EXAMINER

GUERRERO, MARIA F

ART UNIT

PAPER NUMBER

2822

DATE MAILED: 06/16/2003

Please find below and/or attached an Office communication concerning this application or proceeding.

Office Action Summary	Application No. 09/992,192	Applicant(s) KRAMES ET AL.
	Examiner	Art Unit
	Maria Guerrero	2822

-- The MAILING DATE of this communication appears on the cover sheet with the correspondence address --

Period for Reply

A SHORTENED STATUTORY PERIOD FOR REPLY IS SET TO EXPIRE 3 MONTH(S) FROM THE MAILING DATE OF THIS COMMUNICATION.

- Extensions of time may be available under the provisions of 37 CFR 1.136(a). In no event, however, may a reply be timely filed after SIX (6) MONTHS from the mailing date of this communication.
- If the period for reply specified above is less than thirty (30) days, a reply within the statutory minimum of thirty (30) days will be considered timely.
- If NO period for reply is specified above, the maximum statutory period will apply and will expire SIX (6) MONTHS from the mailing date of this communication.
- Failure to reply within the set or extended period for reply will, by statute, cause the application to become ABANDONED (35 U.S.C. § 133). {
- Any reply received by the Office later than three months after the mailing date of this communication, even if timely filed, may reduce any earned patent term adjustment. See 37 CFR 1.704(b).

Status

1) Responsive to communication(s) filed on 30 April 2003 .

2a) This action is **FINAL**. 2b) This action is non-final.

3) Since this application is in condition for allowance except for formal matters, prosecution as to the merits is closed in accordance with the practice under *Ex parte Quayle*, 1935 C.D. 11, 453 O.G. 213.

Disposition of Claims

4) Claim(s) 1-23 is/are pending in the application.
4a) Of the above claim(s) 15-19 is/are withdrawn from consideration.

5) Claim(s) _____ is/are allowed.

6) Claim(s) 1-3,7,9-14 and 20-22 is/are rejected.

7) Claim(s) 4-6,8 and 23 is/are objected to.

8) Claim(s) _____ are subject to restriction and/or election requirement.

Application Papers

9) The specification is objected to by the Examiner.

10) The drawing(s) filed on _____ is/are: a) accepted or b) objected to by the Examiner.

Applicant may not request that any objection to the drawing(s) be held in abeyance. See 37 CFR 1.85(a).

11) The proposed drawing correction filed on _____ is: a) approved b) disapproved by the Examiner.

If approved, corrected drawings are required in reply to this Office action.

12) The oath or declaration is objected to by the Examiner.

Priority under 35 U.S.C. §§ 119 and 120

13) Acknowledgment is made of a claim for foreign priority under 35 U.S.C. § 119(a)-(d) or (f).

a) All b) Some * c) None of:

1. Certified copies of the priority documents have been received.
2. Certified copies of the priority documents have been received in Application No. 09/162,708.
3. Copies of the certified copies of the priority documents have been received in this National Stage application from the International Bureau (PCT Rule 17.2(a)).

* See the attached detailed Office action for a list of the certified copies not received.

14) Acknowledgment is made of a claim for domestic priority under 35 U.S.C. § 119(e) (to a provisional application).

a) The translation of the foreign language provisional application has been received.

15) Acknowledgment is made of a claim for domestic priority under 35 U.S.C. §§ 120 and/or 121.

Attachment(s)

1) Notice of References Cited (PTO-892) 4) Interview Summary (PTO-413) Paper No(s). ____ .
2) Notice of Draftsperson's Patent Drawing Review (PTO-948) 5) Notice of Informal Patent Application (PTO-152)
3) Information Disclosure Statement(s) (PTO-1449) Paper No(s) ____ . 6) Other: ____ .

DETAILED ACTION

1. This Office Action is responsive to the Response filed April 30, 2003.

Claims 1-23 are pending.

Election/Restrictions

2. Applicant's election without traverse of Group II in Paper No. 9 is acknowledged.

Claims 15-19 are withdrawn from further consideration pursuant to 37 CFR 1.142(b) as being drawn to a nonelected invention, there being no allowable generic or linking claim. Election was made without traverse in Paper No. 9.

Priority

3. Acknowledgment is made of applicant's claim for foreign priority under 35 U.S.C. 119(a)-(d). The certified copy has been filed in parent Application No. 09/162,708, filed on September 29, 1998.

Information Disclosure Statement

4. The information disclosure statements (IDS) filed on November 13, 2001 and February 4, 2002 have been considered.

Claim Rejections - 35 USC § 102

The following is a quotation of the appropriate paragraphs of 35 U.S.C. 102 that form the basis for the rejections under this section made in this Office action:

A person shall be entitled to a patent unless -

(b) the invention was patented or described in a printed publication in this or a foreign country or in public use or on sale in this country, more than one year prior to the date of application for patent in the United States.

5. Claims 1-3, 7, 9-14, and 20-22 are rejected under 35 U.S.C. 102(b) as being anticipated by Fujii (EP 0743727 A1) (cited by Applicant).

Fujii teaches a method of fabricating a light-emitting device including an III-Nitride quantum well layer (Abstract). Fujii discloses selecting a facet orientation of the III-Nitride quantum well layer and growing the III-Nitride quantum well layer with the selected facet orientation (col. 3, lines 1-5, 44-50, col. 5, lines 40-55, col. 11, lines 40-55). Fujii teaches selectively growing the III-Nitride quantum well layer with an hexagonal crystal structure of basal plane tilted from a (0001) plane by an angle in the range of 0 degree to a few degrees (col. 6, lines 3-50, col. 11, lines 40-55).

Furthermore, Fujii discloses growing a nucleation layer directly on a substrate surface by metal-organic chemical vapor deposition and growing the quantum well layer above the nucleation layer (col. 13, lines 1-25). Fujii teaches the substrate being SiC or GaN (col. 12, lines 53-55). Fujii discloses growing a first semiconductor layer above the substrate, altering an exposed surface of the first semiconductor layer to provide a surface having the selected facet orientation (col. 12, lines 1-47).

Fujii is silent about selecting the facet orientation to control a field strength of a piezoelectric field therein. However, it is inherent that the selection of the facet orientation control the field strength of a piezoelectric field because the growth orientation of the strained quantum well layer is tilted few degrees from the (0001) direction. Note figures 2A-2B, 3, Abstract.

To serve as an anticipation when the reference is silent about the asserted inherent characteristic, such gap in the reference may be filled with recourse to extrinsic evidence. Such evidence must make clear that the missing descriptive matter is necessarily present in the thing described in the reference, and that it would be so

recognized by persons of ordinary skill. *Continental Can Co. USA v. Monsanto Co.*, 948 F.2d 1264, 1268, 20 USPQ2d 1746, 1749 (Fed. Cir. 1991)

Furthermore, the elements must be arranged as required by the claim, but this is not an *ipsissimis verbis* test, i.e., identity of terminology is not required. *In re Bond*, 910 F.2d 831, 15 USPQ2d 1566 (Fed. Cir. 1990).

Allowable Subject Matter

6. Claims 4-6, 8, and 23 are objected to as being dependent upon a rejected base claim, but would be allowable if rewritten in independent form including all of the limitations of the base claim and any intervening claims.

Response to Arguments

7. Applicant's arguments filed April 30, 2003 have been fully considered but they are not persuasive. Claims 1-3, 7, 9-14, and 20-22 stand rejected. The objection to the Abstract is withdrawn.

In response to applicant's argument that the references fail to show certain features of applicant's invention, it is noted that the features upon which applicant relies (i.e., the strength of the piezoelectric field depends on the strain and the composition of the INGAN strained quantum well layer) are not recited in the rejected claim(s).

Although the claims are interpreted in light of the specification, limitations from the

specification are not read into the claims. See *In re Van Geuns*, 988 F.2d 1181, 26 USPQ2d 1057 (Fed. Cir. 1993).

In response to applicant's argument that Fuji does not show selecting the facet orientation to control a field strength of a piezoelectric field therein, a person of ordinary skill in the art would recognize that it is inherent that the selection of the facet orientation control the field strength of a piezoelectric field because the growth orientation of the strained quantum well layer is tilted few degrees from the (0001) direction. Note figures 2A-2B, 3, Abstract. In addition, Caridi (U.S. 4,952,792) is cited as evidenced to show that Fujii inherently teaches controlling the field strength of the piezoelectric field (Abstract, col. 3, lines 9-40).

Furthermore, to serve as an anticipation when the reference is silent about the asserted inherent characteristic, such gap in the reference may be filled with recourse to extrinsic evidence. Such evidence must make clear that the missing descriptive matter is necessarily present in the thing described in the reference, and that it would be so recognized by persons of ordinary skill. *Continental Can Co. USA v. Monsanto Co.*, 948 F.2d 1264, 1268, 20 USPQ2d 1746, 1749 (Fed. Cir. 1991)

Furthermore, the elements must be arranged as required by the claim, but this is not an *ipsissimis verbis* test, i.e., identity of terminology is not required. *In re Bond*, 910 F.2d 831, 15 USPQ2d 1566 (Fed. Cir. 1990).

Conclusion

8. The prior art made of record and not relied upon is considered pertinent to applicant's disclosure. Caridi (U.S. 4,952,792) is cited as evidenced to show that Fujii inherently teaches controlling the field strength of the piezoelectric field (col. 3, lines 9-40). Sun et al. "Piezoelectric Fields in Strained (In, Ga) As/GaAs Multiple-Quantum well Structures Grown on Vicinal (110) GaAs" (of record) is cited as evidenced to show that the piezoelectric effect is necessary controlled during the selection of the facet orientation.

THIS ACTION IS MADE FINAL. Applicant is reminded of the extension of time policy as set forth in 37 CFR 1.136(a).

A shortened statutory period for reply to this final action is set to expire THREE MONTHS from the mailing date of this action. In the event a first reply is filed within TWO MONTHS of the mailing date of this final action and the advisory action is not mailed until after the end of the THREE-MONTH shortened statutory period, then the shortened statutory period will expire on the date the advisory action is mailed, and any extension fee pursuant to 37 CFR 1.136(a) will be calculated from the mailing date of the advisory action. In no event, however, will the statutory period for reply expire later than SIX MONTHS from the mailing date of this final action.

9. Any inquiry concerning this communication or earlier communications from the examiner should be directed to Maria Guerrero whose telephone number is 703-305-0162.

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If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Amir Zarabian can be reached on 703-308-4905. The fax phone numbers for the organization where this application or proceeding is assigned are 703-308-7722 for regular communications and 703-308-7724 for After Final communications.

Any inquiry of a general nature or relating to the status of this application or proceeding should be directed to the receptionist whose telephone number is 703-308-0956.

MG
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June 10, 2003



AMIR ZARABIAN
SUPERVISORY PATENT EXAMINER
TECHNOLOGY CENTER 2800